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Hardness and surface roughness of hydrogenated amorphous carbon-based films synthesized by atmospheric pressure-plasma enhanced chemical vapor deposition at low temperature

Mayui Noborisaka, Ryohei Horikoshi, So Nagashima, Akira Shirakura, Tetsuya Suzuki

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Authors: Mayui Noborisaka^{a)*}, Ryohei Horikoshi^{a)}, So Nagashima^{b)}, Akira Shirakura^{a)} and Tetsuya Suzuki^{a)}

^{a)}Center for Science of Environment, Resources and Energy, Keio University

3-14-1 Hiyoshi, Kohoku-ku, Yokohama, Japan

^{b)}Korea Institute of Science and Technology

Hwarang-no 14-gil 5, Seongbuk-gu, Seoul 136-791, Republic of Korea

***Corresponding Author:**

Mayui Noborisaka

Center for Science of Environment, Resources and Energy, Graduate School of Science and Technology, Keio University

3-14-1 Hiyoshi, Kohoku-ku, Yokohama 223-8522, Japan

TEL: +81-45-563-1151 (ext. 42070)

FAX: +81-45-566-1495

E-mail: okura0306@gmail.com

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